

# **BEYER WEAVER & THOMAS, LLP**

INTELLECTUAL PROPERTY LAW

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## **FACSIMILE COVER SHEET**

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**APR. 09 2004**

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April 9, 2004

**Receiver:** Group Art Unit: 2877 (Examiner not yet assigned)

**TEL #:** (571) 272-2415

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**Sender:** Henry K. Woodward

**Our Ref. No.:** UCALP011X1

**Re:** 10/716,266

**Pages Including Cover Sheet(s):** 4

**MESSAGE:**

Please see attached Preliminary Amendment.

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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE****RECEIVED  
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In re application of: GENNARI, Frank E.

Attorney Docket No.:  
UCALP011X1/B02-005-3

Application No.: 10/716,266

Examiner: Not yet assigned

Filed: November 17, 2003

Group: 2877

Title: METHOD OF LOCATING AREAS IN AN  
IMAGE SUCH AS A PHOTO MASK LAYOUT  
THAT ARE SENSITIVE TO RESIDUAL  
PROCESSING EFFECTS

Confirmation No.: 6483

**CERTIFICATE OF FACSIMILE TRANSMISSION**I hereby certify that this correspondence is being transmitted  
by facsimile to fax number 703-872-9306 to the U.S. Patent  
and Trademark Office on April 9, 2004.

Signed: \_\_\_\_\_

Laura M. Dean

**PRELIMINARY AMENDMENT**Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Before examination of the subject patent application, please amend the above-identified  
patent application as follows:**Amendments to the Specification begin on page 2 of this paper.****Remarks/Arguments begin on page 3 of this paper.**